Form PTO 1449		U.S. DEPARTMENT	T OF COMMERCE	ATTY DOCKET NO.		SERIAL	SERIAL NO. 10 726 583 New Divisional Application	
(Modified)		PATENT AND TRADEMARK OFFICE		245810US2TTCRD DIV		New Divisional Application		
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LIST OF	REFE	RENCES CITED BY AF	PPLICANT	Yoshinori IIDA, et al.				
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EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	S SUB FILING DATE IF APPROPRIATE		
<b>Ω</b>	AA	6,163,061	12/19/2000	Y. IIDA				
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66-	Ishikawa, T. et al., "Low-Cost 320 x 240 Uncooled IRFPA Using Conventional Silicon IC Process," SPIE, Vol. 3698, Apr. 1999, pps. 556-564.							
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	AZ				Addi	lional Refe	rences sheet(s) attached	
Examiner	1	0/21	696		Date Considered 03/24/04			
*Examiner: Initional conformance a	tial if re	eference is considered, t considered. Include o	whether or not	citation is in conformance with MPEP 60 with next communication to applicant.	09; Draw lin	e through		